## **Unit 3- MOSFETs**

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## Construction & Working of Enhancement-Type MOSFET (Part 1)

MOSFET → Active Device

an control

flow of e => i flow

ea !- BJT, JFET

Passive Device

cn:- Diode, Cap, Trans etc.

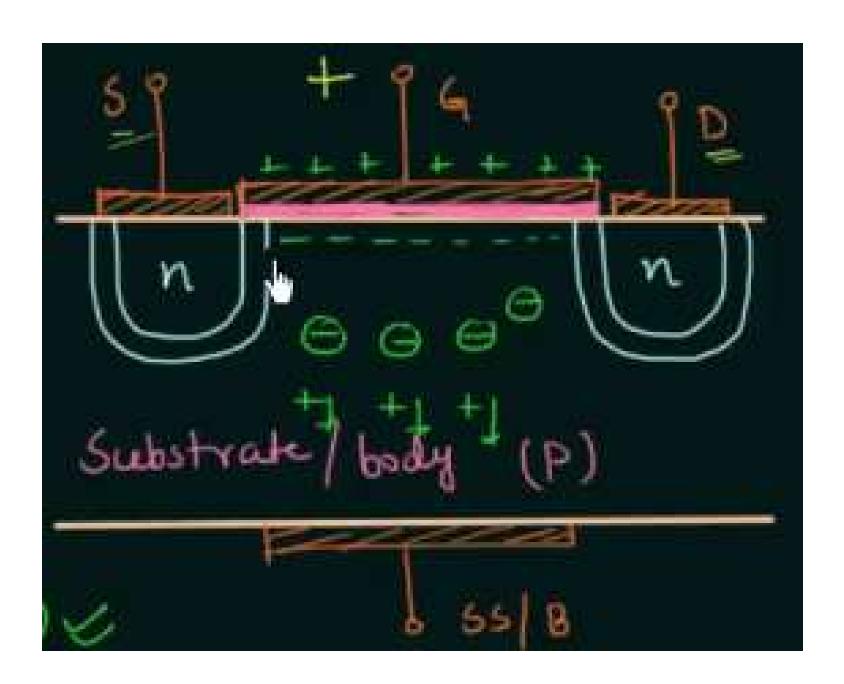
Ut) Depletion - type > p-ch-

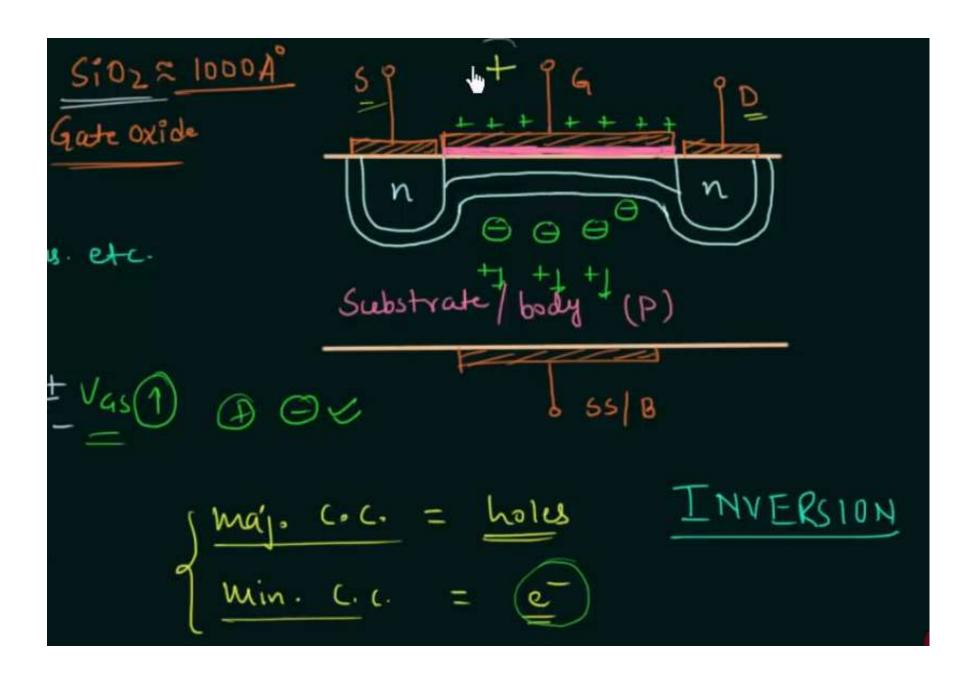
n-ch.

L27 Enhancement -type > p-ch.

Ch. X Das

Si02 = 1000A Gate Oxide ns etc. Substrate/body (P)

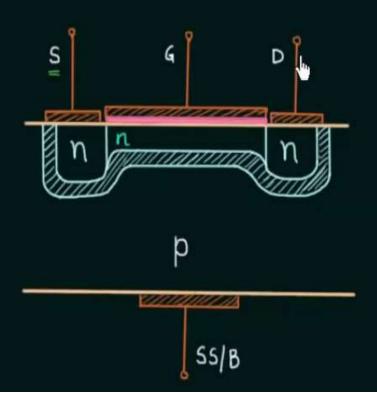




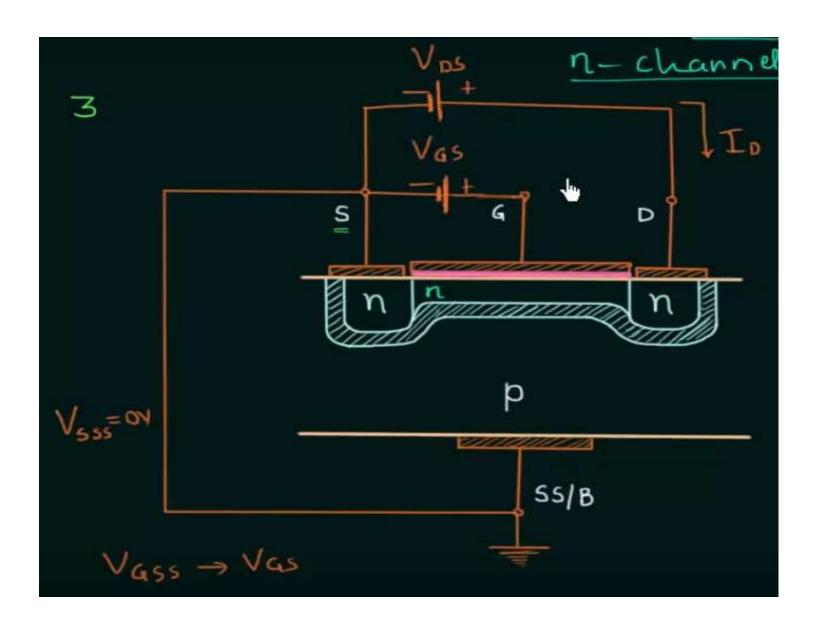
## Construction & Working of Enhancement-Type MOSFET (Part 2)

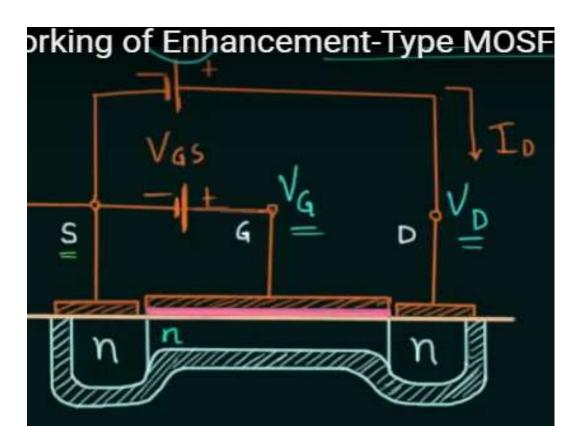
n-channel





V<sub>T</sub>





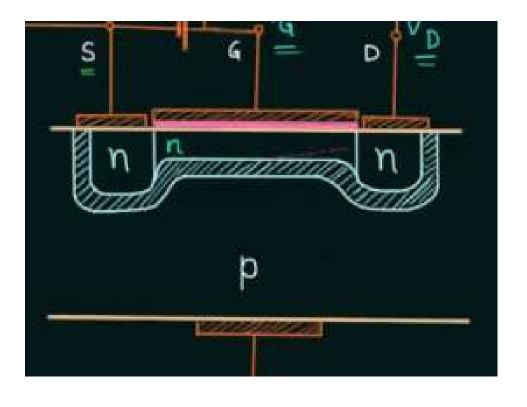
$$V_{4D} - V_{4S} + V_{DS} = V_{D}$$

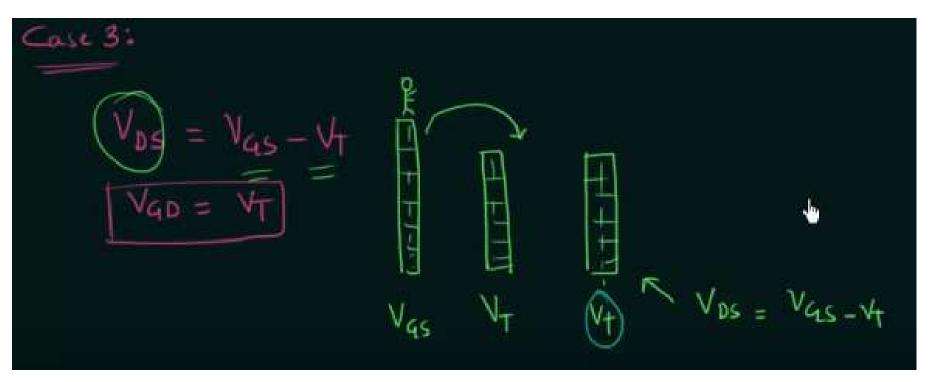
$$V_{4D} = V_{4D} - V_{D} = V_{4S} - V_{DS}$$

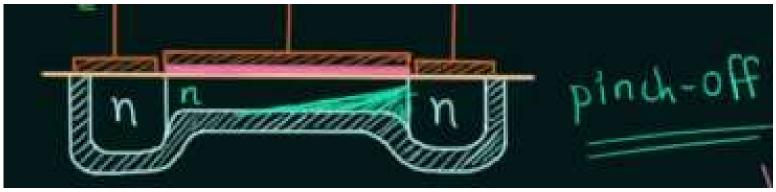
$$V_{4D} = V_{4D} - V_{D} = V_{4S} - V_{DS}$$

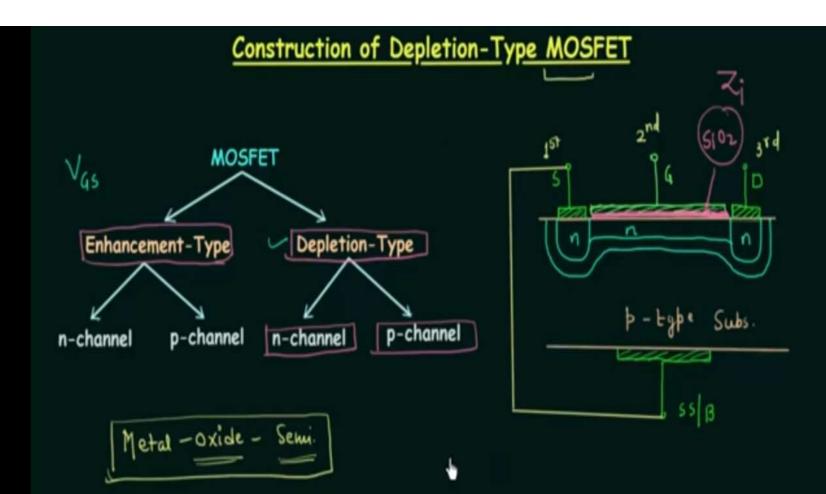
- $I_D = K (V_{GS} V_{GST})^2$
- VGST gate-source threshold voltage
- Square-law type relationship
- K= 0.3 mA/V^2

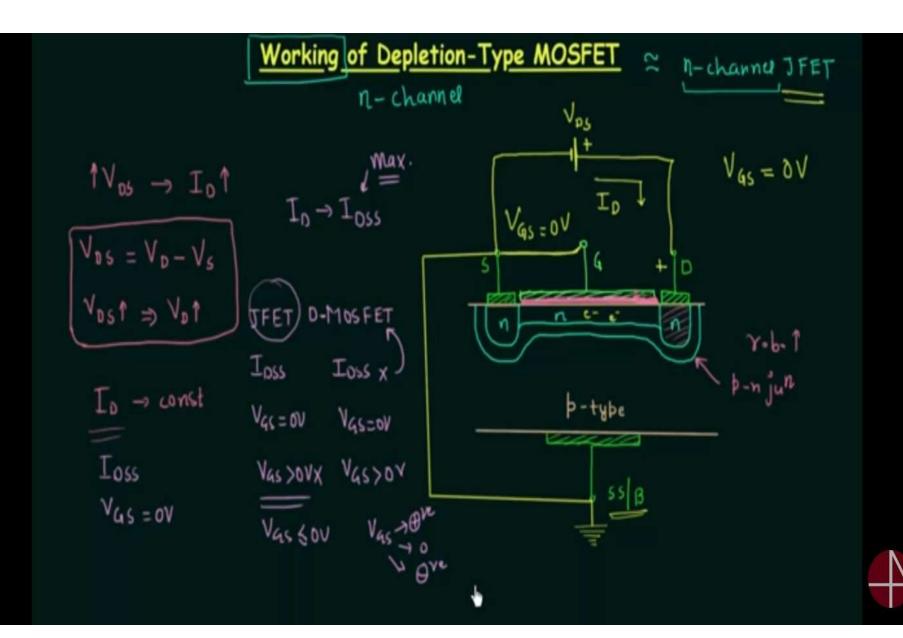
Case 23 VDS > OV V90 1 + V95

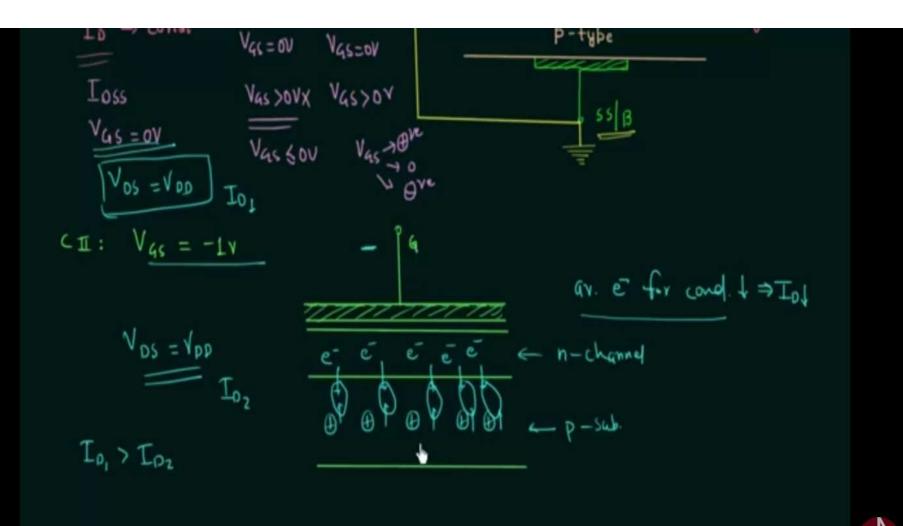












VDS = Vpp Io2

In, > Inz

